

Supplemental Materials:

Tunable polarization properties of charge, spin, and valley in Janus VSiGeZ₄ (Z= N, P, As) monolayers

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TABLE SI. The calculated elastic constants C_{ij} of VSi₂Z₄, VGe₂Z₄, and Janus VSiGeZ₄ in unit of N/m.

	C_{11}	C_{12}	C_{66}
VSi ₂ N ₄	509.186	154.833	177.176
VSi ₂ P ₄	207.034	47.595	79.720
VSi ₂ As ₄	175.202	44.758	65.222
VGe ₂ N ₄	409.370	136.996	136.187
VGe ₂ P ₄	177.692	41.998	67.874
VGe ₂ As ₄	142.668	54.071	44.298
VSiGeN ₄	459.149	144.078	157.536
VSiGeP ₄	194.442	57.213	68.614
VSiGeAs ₄	155.385	45.645	54.870

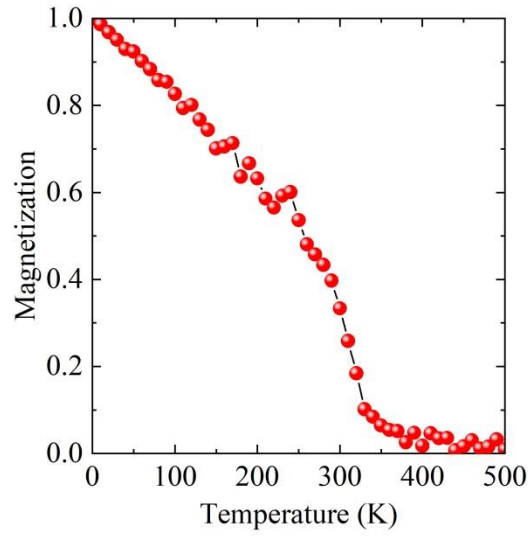


FIG. S1 The magnetization of VSiGeN₄ with temperature.

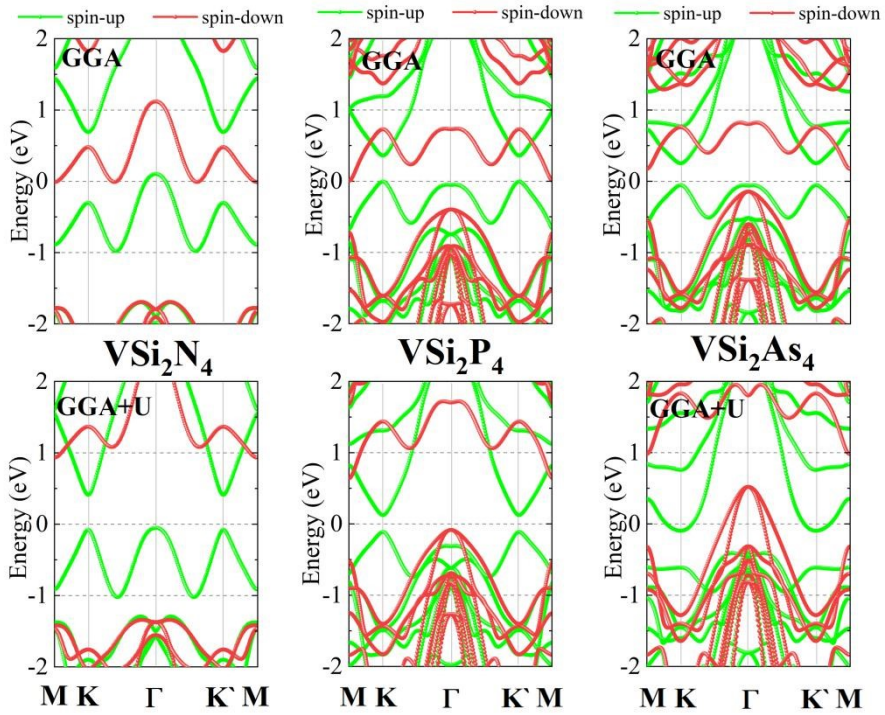


FIG. S2 Spin polarized band structure of VSi₂Z₄ by using GGA and GGA+U methods.

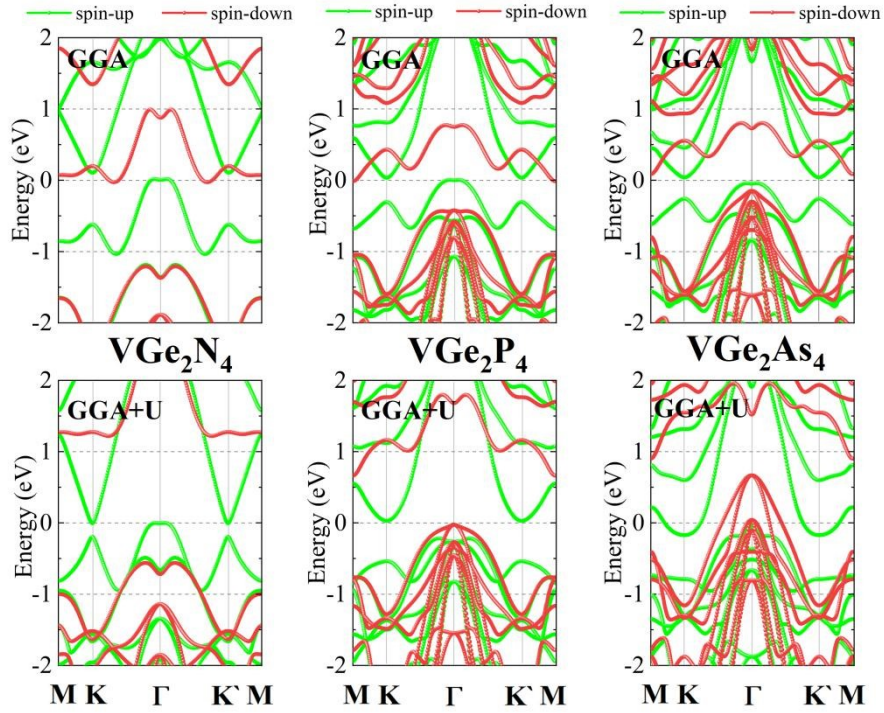


FIG.S3. Spin polarized band structure of VGe_2Z_4 by using GGA and GGA+U methods.

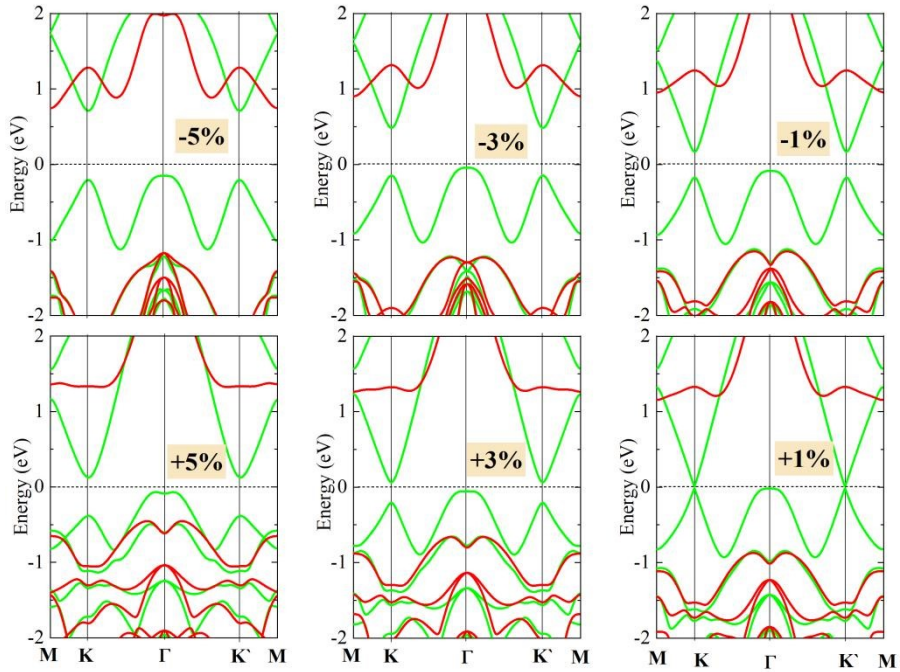


FIG. S4 Spin polarized band structure of the strained $VSiGeN_4$.

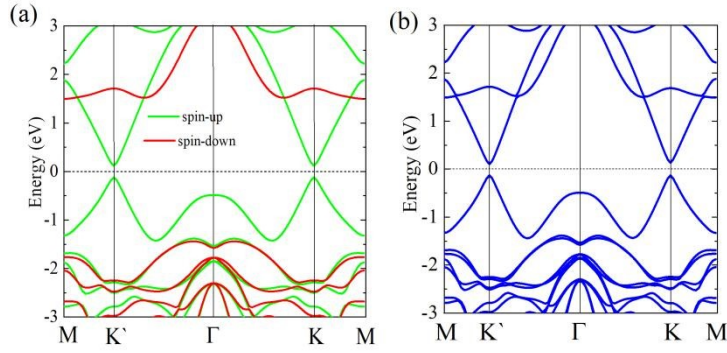


FIG. S5. (a) Spin polarized band structure and (b) band structure with SOC of the strained VSiGeN₄ by using HSE06 level.

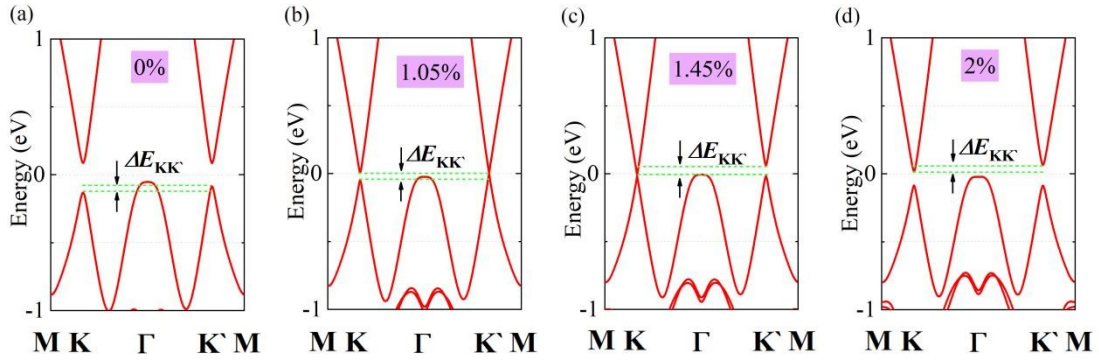


FIG. S6 Band structure of VSiGeN₄ under compressive strain $\varepsilon = 0\%$, $+1.05\%$, $+1.45\%$, and $+2\%$.

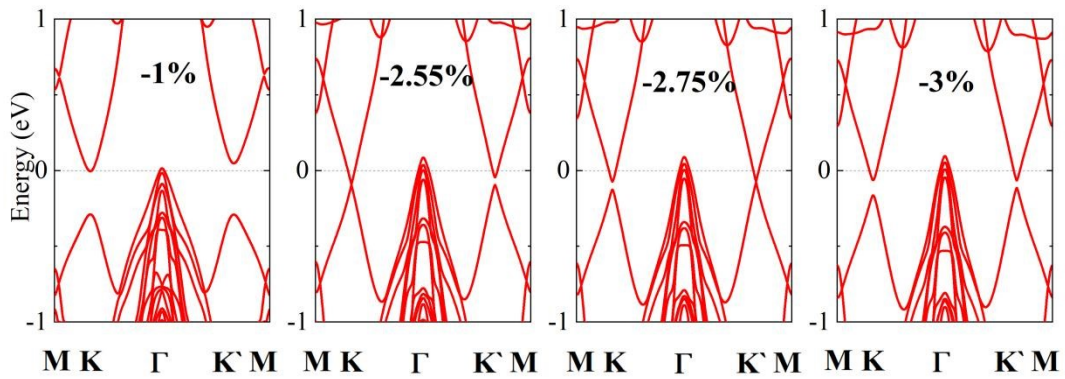


FIG. S7. Band structure of VSiGeP₄ under compressive strain $\varepsilon = -1\%$, -2.55% , -2.75% , and -3% .